

LIST OF ART CITED BY APPLICANT

(Use several sheets if necessary)

Atty Docket No	01-015	Serial No	09/878,658
Applicant		John Albert Hockman	
Filing Date	6/11/2001	Group	1731

U.S. Patent Documents

EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	Class/Subclass	FILING DATE IF APPROPRIATE
JH	AA	3,381,064	1968	Yamaguchi	I	
	AB	3,458,331	1969	Kroyer		
	AC	3,520,705	1970	Fumiko Shido et al.		
	AD	3,802,901	1974	Robertson, et al.		
	AE	3,817,776	1974	M. Gringas		
	AF	3,875,288	1975	Hoffman et al.		
	AG	3,883,364	1975	Robertson, et al.		
	AH	3,926,647	1975	Wuhrer		
	AI	3,941,574	1976	Melkonian et al.		
	AJ	3,956,446	1976	Eirich et al.		
JH	AK	3,967,943	1976	Seeley		

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	Class/Subclass	Translation Yes/No
JH	AL	JP 53-139621	12/78	Japan	I	yes
	AM	JP 55 149122	5/79	Japan		yes
	AN	SU 644 731	1/79	Russia		yes
	AO	SU 823 285	4/81	Russia		yes
	AP	SU 981 217	12/82	Russia		yes
JH	AQ	SU 340 257	5/83	Russia		yes

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

JH	AR	"Glass", Kirk - Ohmer, Encyclopedia of Chemical Technology, 4 th Edition 1994, vol. 12, pp. 555-569, 593-601.
	AS	Mirkovich, V.V., "Utilization of Diopside in the Manufacture of Glass," Mines Branch Technical Bulletin TB 192, Dept. of Energy, Mines and Resources (Ottawa, Canada 1974).
	AT	Mirkovich, V.V. et al., "Utilization of Diopside in the Manufacture of Glass, Part II," Journal of the Canadian Ceramic Society, Volume 44, pp. 43-47, (1975).
Examiner		Date Considered 9/22/2002

*EXAMINER Initial reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

LIST OF ART CITED BY APPLICANT

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Atty Docket No	01-015	Serial No	09/878 658
Applicant John Albert Hockman			
Filing Date	6/11/2001	Group	1731

U.S. Patent Documents

EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	Class/Subclass	FILING DATE IF APPROPRIATE
JH	AA	3,969,100	1976	Kuna et al.	I	
	AB	4,026,691	1977	Lovett et al.		
	AC	4,023,976	1977	Bauer, et al.		
	AD	4,028,131	1977	Pons		
	AE	4,110,097	1978	Chevallier et al.		
	AF	4,252,754	1981	Nakaguchi		
	AG	4,474,594	1984	Lazet		
	AH	4,519,814	1985	Demarest, Jr		
	AI	4,612,292	1986	Richard		
	AJ	4,634,461	1987	Demarest, Jr. et al.		
	AK	4,920,080	1990	Demarest, Jr.	I	
JH	AL	5,004,706	1991	Dickinson		

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		DOCUMENT NUMBER	DATE	COUNTRY	Class/Subclass	Translation Yes No
JH	AM	JP 59 64563	4/84	Japan	I	yes
	AN	JP 2 141454	5/90	Japan		yes
	AO	42 28 500	9/92	Germany		yes
	AP	JP 10 291852	11/98	Japan		yes
	AQ	JP 09 285849		Japan		no
JH	AR	141 105		German		yes

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

	AS	
	AT	
	AU	

Examiner

Date Considered

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<i>JH</i>	AA	5,100,840	1992	Urabe et al.		
<i>JH</i>	AB	5,422,320	1995	Adams, Jr. et al.		
<i>JH</i>	AC	5,900,052	1999	Nakajima et al.		
<i>JH</i>	AD	6,287,378	2001	Fairchild et al.		
<i>JH</i>	AE	6,271,159	2001	Fairchild et al.		
<i>JH</i>	AF	6,287,997	2001	Fairchild et al.		
<i>JH</i>	AG	6,211,103 B1	2001	Tomaino et al.		
	AH					
	AI					
	AJ					
	AK					

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	DOCUMENT NUMBER	DATE	COUNTRY	Class/Subclass	Translation Yes/No
	AL				
	AM				
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	AP				
	AQ				

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	AR	
	AS	
	AT	

Examiner

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